

Introduction of SUZURI Lab



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Next Generation Flexible Technology Yamagata Univ. INOEL

[High barrier, Wet process, Flexible, OLEDs]

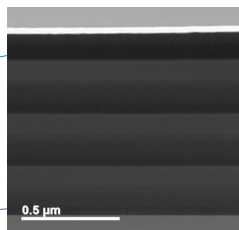
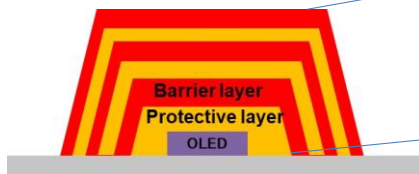
Prof. Yoshiyuki SUZURI

Flexible and transparent OLED panel (200x50mm)



High barrier structure by wet process

**World's first
Wet-TFE technology**



**High barrier structure
by Wet process
at Low temp.
on device**

Condition
- Under N₂
- Room temp.
- VUV irradiation
($\lambda < 200\text{nm}$)

ACS Appl. Mater. & Interfaces, 46, 43425 (2019)

Content: Total research for flexible OLEDs

OLED (Organic Light-Emitting Diode) finds applications not only in displays, but also in a wide range of industrial fields such as lighting, signage, and automobile, because of its unique features such as "flexibility" and "transparency". The key to the widespread use of OLEDs is the "innovative flexible technology" that provides flexible panels at low cost. Our laboratory is researching new technologies in addition to general technologies. We are focusing on (1) flexible panel technology, (2) wet coating process for cost reduction, and (3) demonstration of OLED systems to propose new applications. Large area panels (200 mm sq.) can be fabricated in our lab. Also, we can develop drive circuits for OLED panels.

Appealing point: Wet processed high barrier structure

We have achieved the world's first high barrier by wet process on OLEDs. This is an innovative technology that can be used not only for OLEDs, but also for other devices and packages that need to be protected from water vapor.

ACS Appl. Mater. Interfaces (2019) <https://pubs.acs.org/doi/10.1021/acsami.9b14994>
ACS Appl. Nano Mater. (2021) <https://pubs.acs.org/doi/10.1021/acsanm.1c01862>

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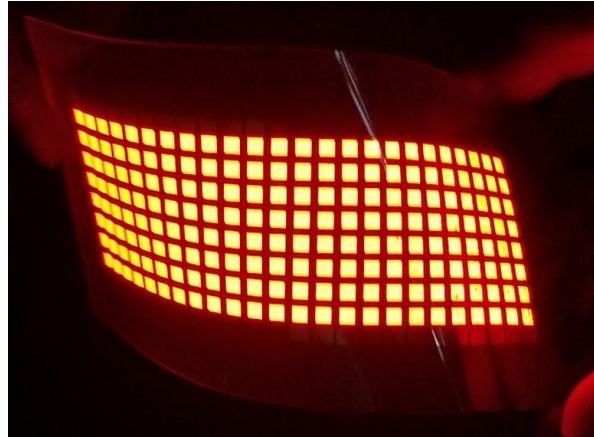


SUZURI Lab's Technology



Thin Films

Dry & Wet Fabrication
Evaluation of films
Device structure
Barrier structure



Panels

cleaning
handling
Processes



Device

Electrical &
Optical Meas.
Durability test

Design

Drive circuits
Panel design

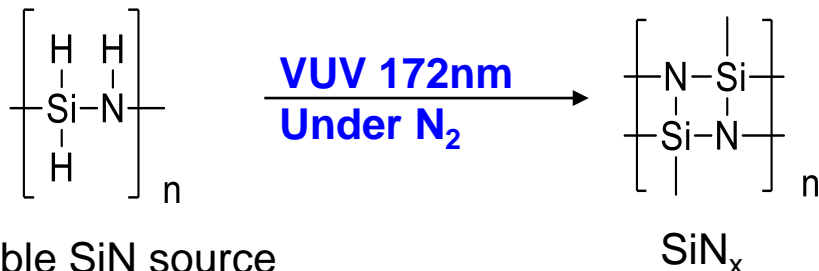
The world first “wet high Barrier technology”

Flexible devices ; from basics to applications

Our Original Tech. : The world first “Wet High Barrier”

Wet coating

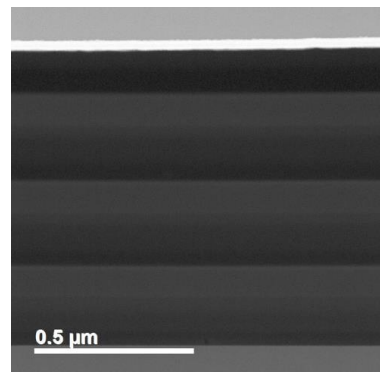
VUV light Irradiation



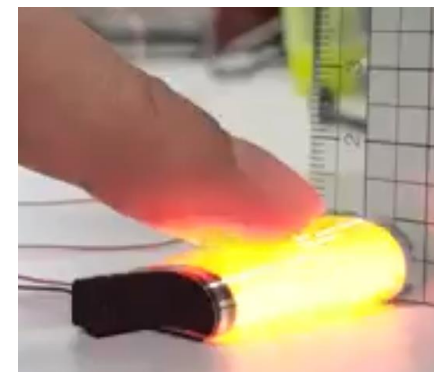
Soluble SiN source

PHPS

(Perhydro-polysilazane)



TEM image of the barrier



Flexible OLED with the barrier : R=5mm

Features

- Under N₂ (inert atmosphere)
- Room temp.
- Vacuum ultraviolet light (VUV : λ<200nm)

Succeeded in **SiN, SiO₂, ZnO, SnO₂, TiO₂**

Our Articles

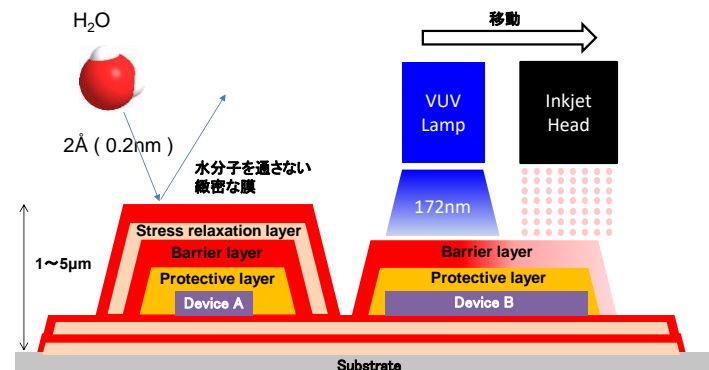
ACS Applied Nano Materials **4**, **10**, 10344-10353 (2021)

ACS Applied Materials & Interfaces, **46**, 43425-4343 (2019)

Journal of The Electrochemical Society, 166 (9) B3176-B3183 (2019)

Organic Electronics, 64, p176-180 (2019)

Society5.0, Industry4.0
High barrier fabricated by IJ

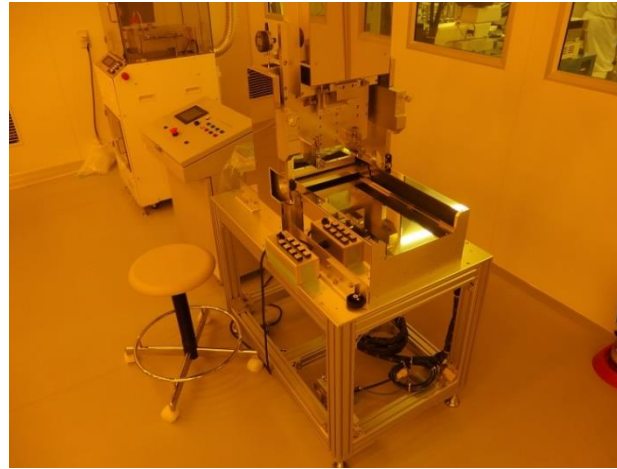


Fabrication System in Clean Room

Vacuum depo., Printing, Coating, Glovebox



Vacuum vapor depo., Sputter
Substrate ~200x200 mm



Slit die coater



Spray coater



Glovebox



Screen printing



Clean room

Film Analysis



Spectroscopic ellipsometry



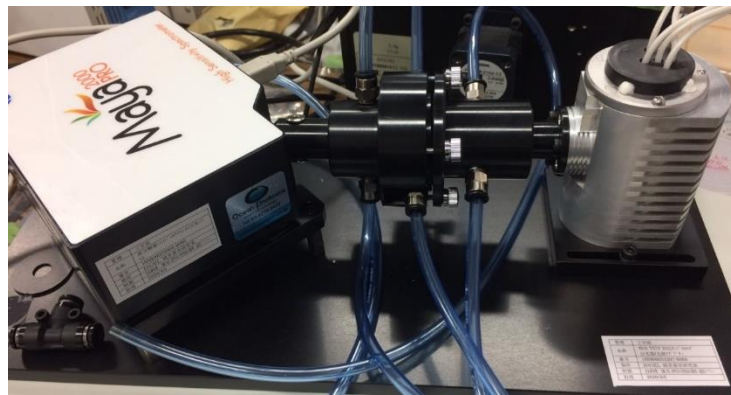
XRD/XRR



Optical film thickness distribution



FT-IR



VUV-absorption Spectra



SEM-EDX

Barrier related equipment



Gas & water vapor transmittance



Adhesion force



Glovebox



VUV irradiation system in glovebox

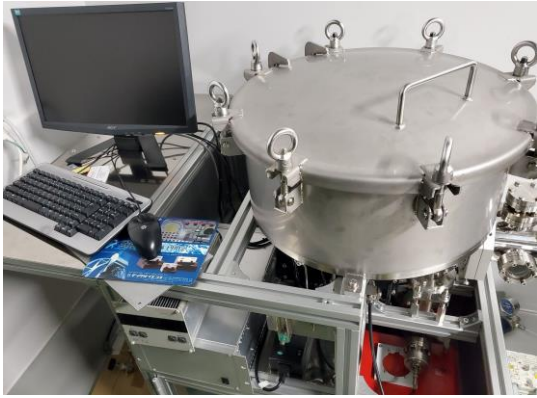


Ink-jet in glovebox

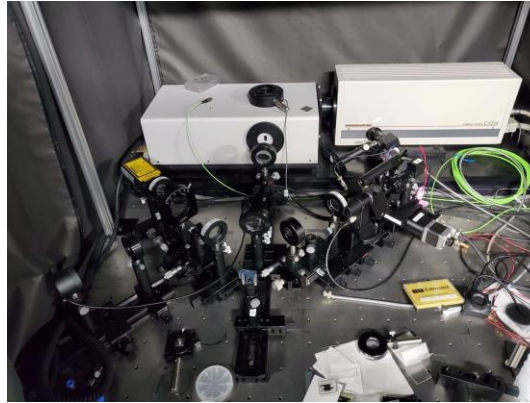


Contact angle measurement

Device Measurement & Film Analysis



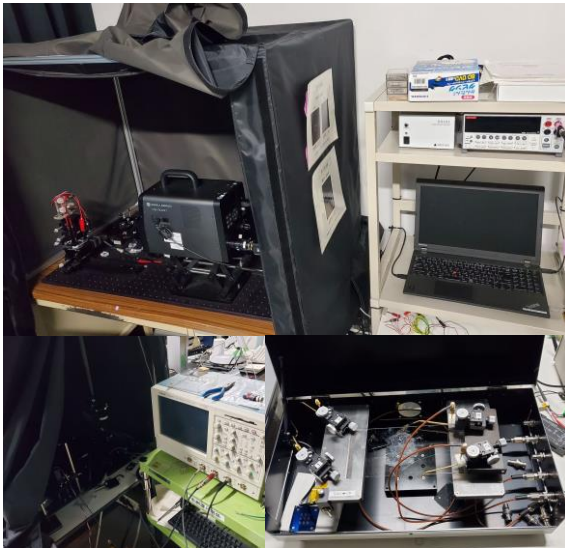
PYS (Ip)



Fluorescent lifetime



PLQY for films



Device performance



Storage test



Continuous driving test
for OLEDs